Review article

Gyeongho Son, Seungjun Han, Jongwoo Park, Kyungmok Kwon and Kyoungsik Yu*

High-efficiency broadband light coupling between optical fibers and photonic integrated circuits

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Abstract: Efficient light energy transfer between optical waveguides has been a critical issue in various areas of photonics and optoelectronics. Especially, the light coupling between optical fibers and integrated waveguide structures provides essential input-output interfaces for photonic integrated circuits (PICs) and plays a crucial role in reliable optical signal transport for a number of applications, such as optical interconnects, optical switching, and integrated quantum optics. Significant efforts have been made to improve light coupling properties, including coupling efficiency, bandwidth, polarization dependence, alignment tolerance, as well as packing density. In this review article, we survey three major light coupling methods between optical fibers and integrated waveguides: end-fire coupling, diffraction grating-based coupling, and adiabatic coupling. Although these waveguide coupling methods are different in terms of their operating principles and physical implementations, they have gradually adopted various nanophotonic structures and techniques to improve the light coupling properties as our understanding to the behavior of light and nano-fabrication technology advances. We compare the pros and cons of each light coupling method and provide an overview of the recent developments in waveguide coupling between optical fibers and integrated photonic circuits.

Keywords: photonic integrated circuits; fiber-to-chip coupling; optical fiber; silicon photonics; optical interconnects.

1 Introduction

Low-loss optical interfaces between different types of optical waveguides are crucial for the efficient and reliable transfer of optical signals in a number of applications, including optical interconnects [1], nonlinear optical signal processing [2, 3], and integrated quantum optics [4]. The optical coupling efficiency between two waveguides is defined by the ratio of guided optical powers before and after the coupling process and can be determined by the waveguide mode overlap condition [5]. Efficient low-loss optical coupling between waveguides made of dissimilar materials is important in providing seamless optical interfaces for heterogeneous photonic integration. Especially, optical coupling between optical fibers and integrated waveguides in the photonic integrated circuits (PICs) and their systems is of growing interest with the recent advances in integrated photonics. Optical fibers have many attractive properties as an optical waveguide, such as low transmission loss, low cost, flexibility, and electromagnetic immunity, and therefore can provide an ideal conduit between various optical components and systems, including PICs [6].

The integration density of optical waveguides in the PIC platform is closely related to the refractive index contrast between the core and the cladding materials. As waveguides based on high-index waveguide core materials with large index contrasts to the cladding have much smaller waveguide dimensions and bending radii, the integration density of such high-index PIC platforms can be significantly increased. As the demand for more compact integrated optical components increases, high refractive index materials, such as silicon [7, 8] and III-V compound semiconductors [9, 10], are required for large-scale high-density PICs. For example, for single-mode operation at telecommunication wavelengths (e.g. 1550 nm), the cross-section of a silicon waveguide (a refractive index of 3.45) embedded in a silica cladding (a refractive index of 1.45) must be on a submicron scale (e.g. 400 nm x 220 nm), and the corresponding guided optical mode profile is highly confined in the waveguide core with a typical mode area on the order of 0.1 μm² [11]. Because of the highly confined
optical modes, a tight bending radius of less than 5 μm can be achieved, which results in ultracompact guided optical components while allowing more flexibilities in the photonic circuit layout.

In contrast to the small mode size of the high-index integrated waveguide, the typical mode-field diameters (MFDs) of standard single-mode fiber (SMF) at telecommunication wavelengths are about 10 μm. The difference in the cross-sectional area between those two waveguides is about 1000 times, which poses a great challenge to efficient optical coupling. For comparison, fiber-to-PIC interfaces for silica-based planar lightwave circuits [12–14] can achieve very high coupling efficiencies of up to −0.05 dB (98.9%) [14] mainly because the integrated waveguides and optical fibers are made of the similar silica materials with low-index contrasts and they have similar waveguiding properties, such as mode profile and effective modal index.

Significant efforts have been made to improve various aspects of fiber-to-PIC light coupling, and the important figures of merit (FOMs) include coupling efficiency, operating wavelength range or bandwidth, polarization sensitivity, misalignment tolerance, and scalability. In this article, we review three important classes of optical coupling schemes between optical fibers and integrated waveguides based on high refractive index materials, such as silicon, in the near-infrared wavelength range and compare their performances based on the FOMs. In our classification, the three major fiber-to-PIC light coupling methods are end-fire coupling, diffraction grating-based coupling, and adiabatic coupling.

The end-fire coupling methods have been mainly used for low-port-count photonic chip packaging. Although end-fire coupling provides broadband and polarization-insensitive optical coupling properties, it typically requires precise alignment tolerances on the order of ±0.5 μm for 1-dB excess optical losses [15]. Recent progress and notable achievements in end-fire coupling are reviewed in Section 2.

In Section 3, we review diffraction grating-based optical coupling. Grating coupling has three representative advantages compared to end-fire coupling: post-processing, such as dicing or polishing, is not required, which allows in-process wafer-scale optical characterization and testing; the coupler structures do not need to be located at the chip edges, which improves layout design flexibility and optical port scalability; and alleviated alignment tolerance makes measurement and packaging processes simpler. The grating-based couplers are, however, polarization- and wavelength-dependent and show relatively low coupling efficiencies when compared to the end-fire couplers.

Adiabatic coupling seems similar to end-fiber coupling but is based on evanescent power transfer through waveguide tapers and can achieve very high coupling efficiency, broadband coupling, and compact coupler footprint. Recent progresses in this method are reviewed in Section 4.

2 End-fire coupling

Because of its physical proximity between optical waveguides’ end facets, end-fire coupling (also referred to as butt coupling or edge coupling) is considered as the most straightforward way to connect two different waveguides and transfer optical signals between them. End-fire coupling between the optical fiber and the integrated waveguide for the chip-scale PIC platform has therefore been a well-established approach for relatively low port count connections, and examples include fiber-pig-tailing for semiconductor laser chips [16–18], input and output fiber connection for optical waveguide-based modulators [19], and optical switches [20, 21]. Figure 1A and B show a schematic diagram of single-mode fiber-to-laser chip coupling and an example of a packaged device, respectively [18]. Although it is possible to use lenses and other discrete
optical components between the fiber and the PIC chip to improve the optical coupling characteristics, we mainly focus on the direct end-fire coupling schemes without bulk optics in this review. In 1977, Hunsperger et al. [17] adopted an end-fire coupling method to directly couple the light output from a GaAs semiconductor laser to a Ta2O5 waveguide without an intermediate optical fiber. Burns et al. [22] and other researchers [23, 24] also introduced end-fire coupling schemes between optical fibers and LiNbO3 (or LiTaO3) diffused channel waveguides. End-fire coupling methods for InP/InGaAsP waveguides [25–27], GaAs/AlGaAs waveguides [28–30], and photodiodes [31, 32] with low wavelength and polarization dependencies were also developed. By using a tapered waveguide structure (larger waveguide dimensions toward the terminating end), the end-fire optical coupling techniques with the diffused channel waveguides exhibited low optical insertion losses less than 1 dB [25]. Researchers have also employed tapered waveguide structures with larger facet sizes [23, 26, 27] to extend the effective optical mode diameter, up to the order of 10 μm, and efficiently coupled the light signal to the glass optical fibers with similar MFDs. These approaches also show small wavelength- and polarization-dependent losses of less than 1 dB.

In this section, we start our discussion by introducing the operating principle of end-fire coupling in Section 2.1. Notable research achievements with tapered waveguide structures are reviewed in Section 2.2. Enhanced optical coupling schemes with intermediate waveguide regions (Section 2.3) and vertically curved and suspended waveguide structures (Section 2.4) are also reviewed. Table 1 compares the performances of various end-fire coupling schemes according to the major FOMs.

2.1 Principle of operation

Figure 2A schematically (not drawn to scale) shows a typical end-fire coupling scenario between two waveguides with an arbitrary intermediate coupling region. In this review article, we are mostly interested in passive optical coupling between an optical fiber and an integrated waveguide and assume that the input optical power from the input waveguide (waveguide 1 in Figure 2A, e.g. a silica-based single-mode optical fiber) is carried by a guided optical mode, whose field profile is given by $E_1$. In this analysis, we pay our attention only to a specific input mode $E_1$, but the same analysis can be applied to other input modes that are orthogonal to $E_1$. We further assume that the output waveguide (waveguide 2 in Figure 2A, e.g. a silicon waveguide) can support multiple guided
The input guided mode in the waveguide 1 ($E_1$), for example, the HE_{11} mode in the SMF, incoming electromagnetic field after passing through the intermediate coupling region ($E'$); output guided modes in the waveguide 2 ($\sum E_{2,k}$). Non-coupled radiation modes ($E$) are not shown.

The guided mode of the input waveguide ($E_1$) is first radiated through the intermediate coupling region after partial reflection and transmission (with a transmission coefficient of $t_1$) at the end facets of the waveguide. The radiated optical field ($E$) propagates through the intermediate coupling region and arrives at the front facet of the waveguide 2. The optical field measured in front of the waveguide facet is given by $E'$, which can be finally coupled to the output guided modes $\sum E_{2,k}$. The coupling efficiency between $E'_1$ and $E_{2,k}$ can be quantitatively obtained from the overlap integral ($\eta$) and the transmittance ($|t_1|^2$). Partial reflections may occur at the interfaces due to the differences in the effective refractive indices, and the corresponding transmission coefficient is given by $t_2 = 2(n_{eff,1}/n_{eff,2,k})^{1/2}/(n_{eff,1} + n_{eff,2,k})$, where $n_{eff,1}$ is the effective refractive index for the intermediate coupling region and $n_{eff,2,k}$ is the effective modal index for the $k$th guided mode in the output waveguide.

A typical single-mode optical fiber has only one guided mode (fundamental HE_{11} mode) when considering only one polarization state. The incoming electric field ($E'_1$) can be decomposed into the linear combination of the orthogonal guided modes ($E_{2,k}$) of the output waveguide and the non-guided modes ($E$) and is given by [45] the following:

$$E'_1 = \sum_{\text{guided}} c_k E_{2,k} + \int c_{\text{radiation}} E_{\beta} \, d\beta,$$

where the expansion coefficient $c_k$ can be obtained using the Poynting theorem and is given by the following:

$$c_k = \frac{\int E'_1 \times H_{2,k}^{*} \, dA}{\int E_{2,k} \times H_{2,k}^{*} \, dA}.$$

The overlap integral between the incoming field ($E'_{1}$) and the $k$th guided mode is given by the following:

$$\eta_k = \frac{\int E_{1} \times H_{2,k}^{*} \, dA}{\int E_{1} \times H_{1}^{*} \, dA} = \frac{\int \left| E_{1} \times H_{1}^{*} \right|^2 \, dA}{\int \left| E_{1} \times H_{1}^{*} \right|^2 \, dA}$$

The overlap integral in Equation 2.3 represents the similarity of the optical field profiles between $E'_1$ and $E_{2,k}$. In addition to the field overlap, we need to take into account the partial optical reflections at the interface, resulting from the abrupt changes in the effective refractive index. Therefore, the total optical power coupling efficiency from the incoming field $E'_1$ into the $k$th guided mode for the output waveguide ($E_{2,k}$) is finally given by $|t_2|^2 \cdot \eta_k$. The optical power transfer efficiency from the input waveguide mode ($E_1$) to the field profile in front of the output waveguide ($E'_1$) can be similarly obtained as described above. When the intermediate coupling region consists of, for example, free-space, the radiated beam from the input waveguide 1 (e.g. silica-based optical fiber) diverges with a numerical aperture (NA) determined by the core ($n_{clad}$) and cladding ($n_{clad}$) indices [NA = ($n_{core}^2 - n_{clad}^2$)^1/2], and the full divergence angle is $2\theta_B = 4\lambda/(2\pi \times W_p)$, where $W_p$ is the beam waist radius. The detailed electric field profile with respect to the propagation distance from the waveguide end facet can be obtained from the diffraction theory. Because of rapid beam divergence, when the distance between the waveguides is too far, the incident beam profile ($E'_1$) shows a low overlap integral value with $E_{2,k}$, and results in a low coupling efficiency to a specific output mode. We also need to consider partial reflections at the interfaces between waveguide 1 and the intermediate coupling region ($E_1$ and $E$) and between the intermediate coupling region and waveguide 2 ($E'_1$ and $\sum E_{2,k}$) due to the different effective indices in each region.

There exist various strategies to improve the overall optical coupling efficiencies. For example, three-dimensional tapered waveguide structures can be used to...
mitigate the MFD mismatches between the input and output waveguides \( (E_1, E_2) \) and thereby increase the overlap integral values \( (\eta) \). Another way to improve the coupling efficiency is by lowering the partial reflections at the interfaces \( (t_1, t_2) \) with intermediate index regions, such as oxide and polymer layers instead of air, due to the reduced effective index contrast. In addition to using the lower index material in the intermediate coupling region, the waveguide itself can be inversely tapered (sharper waveguide tip) to provide gradual transformation of the effective index as well as to obtain lower effective modal index toward the transition region.

### 2.2 Tapered waveguides

Lateral [46, 47], vertical [48], and three-dimensional [49, 50] waveguide taper designs have been introduced to enhance the effective MFD of the integrated waveguides with high-index core materials (e.g., III–V compound semiconductor and silicon). These types of intermediate coupling structures are also referred to as spot-size converters (SSCs or mode-size converters) [51] and gradually increase the width and/or height of the integrated waveguide to provide a large terminating facet area up to 100 \( \mu \text{m}^2 \), which is close to that of the fiber core, as schematically shown in Figure 3A. The tapering angle of the SSC transition region needs to be carefully designed to prevent unwanted light coupling to the higher order modes for the tapered waveguide region. An extended waveguide facet dimension through the SSC can achieve an enlarged electromagnetic field profile, resulting in a higher mode overlap value \( (\eta) \), as described in Section 2.1.

Three-dimensionally tapered SSCs have been employed in the silicon-based PIC platform for efficient optical coupling between optical fibers and integrated silicon waveguides [33–37, 52, 53]. Such SSC structures can be fabricated with conventional silicon waveguides on silicon-on-insulator (SOI) wafers using additional fabrication processing steps, such as polishing [52], etching [34, 36, 37, 53], and gray-tone shadow masking [33, 35, 54]. As shown in a scanning electron microscope (SEM) in Figure 3B, Shiraishi et al. used a metal shadow mask fabrication process [54] to make a vertical waveguide taper [35]. Starting from the silicon waveguide cross-section of 500 nm in height and 300 nm in width, a total taper length of 2 mm and a final waveguide width of 10 \( \mu \text{m} \) were achieved with a linear taper. The final waveguide width is close to the standard single-mode fiber MFD. Amorphous hydrated silicon (a-Si:H) was deposited to extend the vertical mode dimensions in the laterally extended silicon waveguide. A measured net transmission loss of 0.5 dB was obtained at the input wavelength of 1.55 \( \mu \text{m} \) using a lensed fiber.

Although this type of guided mode expansion approaches offers good coupling efficiency of better than −1 dB and seems straightforward in concept, it requires additional dedicated fabrication steps, such as thick materials deposition and etching. It might also occupy more space when compared to other coupling schemes.

### 2.3 Enhanced optical coupling with intermediate waveguide regions

Optical mode profiles and their cross-sectional areas can be extended not only by expanding the waveguide

![Figure 3](image-url)
dimensions with waveguide tapers as discussed in the previous section but also by shrinking the waveguide dimensions, as schematically shown in Figure 4A. When the waveguide cladding material has an intermediate refractive index (larger than air but smaller than the waveguide core refractive index) and thus provide a smaller index contrast, the optical modes are less confined to the waveguide core as the core dimensions decrease, resulting in larger effective mode areas and smaller effective modal index. The low-index intermediate cladding layers, such as polymer [38, 39, 56–58], SiO₂ [55, 59–62], and Si₃N₄ or SiON [40, 62, 63] with effective refractive indices comparable to optical fibers, can efficiently expand the optical mode dimensions and reduce the partial reflections at the interfaces [38–40, 55–63]. The input light gets adiabatically expanded through the inversely tapered high-index waveguide and can be finally coupled to the optical fiber with high coupling efficiency.

Figure 4B shows an example of an inversely tapered waveguide coupler, which transforms both the effective mode size and effective mode index between an optical fiber and an integrated silicon waveguide [55]. The inversely tapered silicon waveguide (smaller waveguide dimensions toward the terminating end) has a tapering length of ~40 μm, and the waveguide width reduces from ~470 nm (single-mode waveguiding condition) to ~100 nm with a waveguide height of 270 nm. Due to the expanded mode size at the subwavelength-scale waveguide tip, the maximum mode overlap with an input lensed fiber (MFD = ~5 μm) was calculated to be as high as 94%, and this corresponds to a mode mismatch loss of 0.26 dB. The total insertion losses with partial reflections and misalignment were measured to be ~3.3 dB and 6.0 dB for the TM (an effective refractive index of 1.51) and TE (an effective refractive index of 1.31) modes, respectively [55]. Although there is a large index contrast between the silicon core material and the SiO₂ cladding layer, the propagating electromagnetic field for the very narrow inversely tapered waveguide structure resides mostly outside the core region and its effective modal index becomes close to the refractive index of the SiO₂ cladding layer.

Using a similar approach with a combination of an intermediate polymer region and a SiO₂ cladding layer, Pu et al. reported very low optical coupling losses of ~0.36 dB and ~0.66 dB for the TM and TE modes, respectively [39] (Figure 4C). The ultra-low losses were obtained using a very narrow silicon taper tip whose width was reduced from ~40 nm to ~12 nm by silicon oxidation.

To further improve the fiber-to-chip optical coupling efficiency with intermediate waveguide structures, suspended waveguide structures with low-index cladding materials, such as SiO₂ [41, 42, 64–66] and SiON, were investigated [67], as schematically shown in Figure 5A. Figure 5A shows a tapered silicon waveguide, surrounded by a SiO₂ cladding cantilever structure, is suspended [65]. After formation of the tapered silicon waveguide and SiO₂...
cladding cantilever structure (13 μm × 10 μm), the underlying Si substrate was etched to form a trench, as shown in Figure 5A. The optical power leakage to the substrate was minimized by providing a sufficiently large trench depth. The coupling efficiencies were measured to be −1.5 dB and −1.0 dB for the TM and TE modes, respectively. As the suspended waveguide structures have an alignment tolerance of approximately ±2.0 μm for a 1-dB excess loss, which is better than other end-fire coupling schemes, it may have benefits in the fiber assembly and packaging processes [42, 65]. Multi-layered suspended tapering structures can further improve the coupling efficiencies by gradually transforming the effective refractive index between high-index silicon waveguides and low-index optical fibers [62, 64–66].

This type of end-fire coupling with inversely tapered high-index waveguides can achieve efficient optical coupling with small footprints and low wavelength/polarization dependencies. Similar approaches in this category include waveguide ribbon layers [68–70], photonic wire bonding [71–73], and free-form lenses and mirrors [74, 75]. Figure 6A and B show examples of single-channel SSC

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**Figure 5:** (A) Schematic diagram of a suspended intermediate waveguide structure. (B) An example of an inversely tapered silicon waveguide surrounded by a SiO2 cladding with a cantilever structure. The SEM images of the fabricated couplers are shown. Adapted from Ref. [65]. Copyright (2011) The Optical Society.

interconnects [69, 70]. Multi-port coupling examples using photonic wire bonds and free-form components are illustrated in Figure 6C [71] and D [74], respectively. Recently, several researchers have exploited subwavelength grating (SWG) converters based on high-index materials, such as silicon [76–78]. By engineering the effective refractive index of the waveguides, SWG-based end-fire couplings can achieve coupling efficiencies as high as −0.32 dB (93%) [78].

### 2.4 Vertically curved and suspended waveguide structures

One of the main disadvantages of the conventional end-fire coupling methods is that the optical interfaces to the input/output fibers need to be located at the PIC chip edges and the dicing process is required to expose the end-fire coupler structures to the optical fibers. However, the out-of-plane light coupling can be achieved by physically bending the waveguides toward the upward direction from which the optical fibers are approached [43, 44, 79, 80], as schematically shown in Figure 7A. While providing the advantages of conventional end-fire coupling, such as low wavelength and polarization dependencies, this out-of-plane coupling scheme does not require the optical couplers to be located at the chip edges.

The bent waveguide couplers can be fabricated by introducing stress gradients to the waveguide structure so that the waveguide termination region can be bent upward when released from the substrate [81, 82]. The overall footprint for the bent waveguide coupler is closely related with its bending radius. As highly confined optical modes in the high-index waveguides allow small bending radii of less than 10 μm without too much radiation losses occurring, the vertically curved waveguide coupler design can be compact and scalable while providing the benefits of end-fire coupling.

For example, out-of-plane optical coupling to the optical fibers or free-space optical beams was obtained by stress-engineered Si/SiO₂ cantilevers deflected upward by thermal annealing stress, as shown in Figure 7B [79]. Tapered silicon waveguides were embedded in the center of the SiO₂ cantilevers. After the deposition of PECVD SiO₂ layer, the SiO₂ cantilevers are released from the substrate by reactive ion etching and subsequently annealed for stress control. Maximum deflection and tilt angles at the end of a 40-μm-long SiO₂ cantilever with silicon core in the center are 2.6 μm and 4.7°, respectively. Because of limitations in maximum stress level from the thermal annealing process, the bending radii obtained from this method were limited to approximately 100 μm [79, 83]. To introduce higher stress gradients and thereby reduce the bending radius of the curved waveguide structure for smaller coupler dimensions, an ion beam implantation method was applied to intentionally introduce lattice defects. As a result, a bending radius of approximately 3 μm was obtained, as shown in Figure 7C [44]. The vertically curved waveguide coupler structures showed −1 dB

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**Figure 7:** (A) Schematic diagram of a vertically curved intermediate waveguide structure. (B) SEM image of a curved coupler using thermal annealing. Reprinted from Ref. [79]. Copyright (2009) The Optical Society. (C) SEM image of a bent waveguide coupler with a radius of curvature of 3 μm using ion implantation. Reprinted from [44]. Copyright (2016) The Optical Society/IEEE.
(80%) optical coupling efficiencies with tapered fibers [43, 79] and lensed fibers [44, 80].

3 Diffraction grating-based optical coupling

Diffraction grating-based optical coupling methods have been proposed, as an alternative solution to end-fire coupling, to deal with mode size mismatches between optical fibers and integrated waveguides in the PIC platforms as well as to provide scalable optical interfaces from the surface-normal direction instead of chip edges [84]. Surface-corrugated grating structures with subwavelength-scale feature sizes are usually patterned in the PIC's waveguide layer to create a coherent constructive interference condition that diffractively couples the incident free-space optical beam from the optical fiber into the high-index waveguides, or vice versa. In 2002, Taillaert et al. presented an out-of-plane coupling method for efficient light transfer between the optical fibers and planar waveguides using grating components on a 240-nm-thick GaAs core material with an oxide cladding layer [29]. Because of its out-of-plane coupling geometry, the grating couplers do not need to be located on the chip edges and thus enable wafer-scale PIC characterization capabilities without requiring chip dicing and polishing. The grating couplers have a typical tolerance value of ±2 μm for 1-dB excess losses [85]. This is a relaxed spatial alignment tolerance compared to the end-fire coupling methods.

Initial works on the integrated diffraction grating structures have first focused on manipulation and collimation of free-space optical beams [86–88] or output light collimation from the laser diodes [89–91]. Coupling of the laser beam to a thin glass film was experimentally achieved using a periodic grating structure made from photoresists directly fabricated on the glass film [87]. A blazed grating structure was also proposed to enhance the directionality and coupling efficiency [92]. In the 2000s, with the emergence of foundry-based silicon photonics platforms, grating couplers began to be fabricated on SOI wafers and intimately integrated with PICs using batch microfabrication processes, which enabled scalable surface-normal optical interfaces between the optical fibers and PIC platforms [93–95]. In addition, polarization-diversity grating couplers were implemented by taking advantages of polarization splitters/combiners [96–99], and a low polarization-dependent loss comparable to the end-fire couplers (<1 dB) was achieved [99]. Since 2010, based on advances in fabrication techniques, the SWG structures have been also exploited in surface coupling methods to improve the coupling efficiencies [100–102] and obtained polarization-independent operation [103] by engineering the effective refractive indices for different input polarization states. SWG-based couplers can also achieve a wide 3-dB spectral bandwidth of ~117 nm by tailoring the dispersion of the grating structures [104]. Moreover, arrays of grating couplers and fibers, including multi-core fibers, have been introduced to facilitate large-scale packaging and multiple-port parallel device characterization [105–108].

In this section, the operating principle of diffraction grating-based optical couplers is first introduced in Section 3.1. Figure 8A shows an overall schematic diagram of a typical grating coupler (not drawn to scale). Figure 8B

![Figure 8: Diffraction grating-based optical coupling with uniform grating components. (A) Schematic diagram of a diffraction grating-based coupling structure. (B) Cross-section view of (A).](image-url)
shows its $z$-$y$ plane cross-sectional view with the directions of the diffracted light components. We consider a simple case where the grating is composed of diffractive elements placed along the waveguide propagation direction. Although the diffraction grating-based coupling schemes can be in principle applied to various materials, we mostly focus on the silicon-based PIC platform in this review article. The efficient fiber-to-chip coupling can be typically achieved using a combination of an adiabatically tapered waveguide region for horizontal mode size conversion and a grating coupler with a $\sim 10$-$\mu$m width similar to the MFD of typical SMFs at telecommunication wavelengths around 1550 nm [95]. The waveguide taper region connects a single-mode waveguide with a grating coupler and transforms the optical field distribution along the width direction ($x$-axis in Figures 8 and 9) perpendicularly to the waveguide’s propagating axis ($z$-axis in Figures 8 and 9). The grating elements diffract the guided optical beam out of the waveguide plane, and the diffracted optical beam finally couples to the optical fiber’s guided mode.

The coupling efficiency between the obliquely (or sometimes vertically) incident free-space optical beam and the guided light in the integrated waveguide for this basic grating coupler is often limited by two factors. First, some optical losses result from the optical field profile mismatch between the fiber’s propagating mode and the free-space optical beam diffracted upward from the grating coupler. Second, when the light transmitted through the waveguide meets the grating structure, it propagates not only to the upper cladding part but also to the lower substrate, which reduces the overall coupling efficiency toward the optical fiber. To obtain better efficiencies, grating-based coupling methods have employed arrays of apodized diffractive elements, achieving both enhanced directivity and mode overlap. Additional optical feedback structures, such as additional backside mirrors, have also been used to further increase the coupling efficiency. Apodized grating structures (Section 3.2) and directionality-enhanced grating structures (Section 3.3) can resolve the major loss factors for the grating couplers, and their development progresses are reviewed in this section. Table 2 lists the performances of various diffraction grating-based optical couplers.

### 3.1 Principle of operation

Although the analytic framework discussed here is based on a simple diffraction theory, it can predict various aspects of diffraction grating-based optical coupling behaviors with reasonable accuracy [116]. A grating coupler is usually composed of periodically located multiple diffractive elements, and the light diffraction angles from such optical structures can be described by the conventional diffraction theory and the so-called Bragg condition [84]. The Bragg condition for wavevectors parallel to the optical waveguide axis ($z$-axis in Figures 8 and 9, and in this section, we assume that the light propagation direction is toward $-z$ from the integrated waveguide to the optical fiber) shows that the difference between the waveguide propagation constant ($\beta = 2\pi \cdot n_{\text{eff}}/\lambda_0$, where $n_{\text{eff}}$ is the effective refractive index of the waveguide and $\lambda_0$ is the free-space optical wavelength) and the surface-parallel component of the wavevector of the diffracted wave ($k_z$) should be matched to an integer multiple ($m$) of the grating’s wavevector ($K = 2\pi/\Lambda$, where $\Lambda$ is the grating period) and is given by $\beta - k_z = m \cdot K$. Depending on the input wavelength and grating period, multiple diffraction orders can be generated toward both the

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**Figure 9:** Wavevector representation of the Bragg condition for the grating coupler.
(A) Perfectly vertical operation, which generates the second-order diffraction ($m = 2$) with increased back-reflection. (B) Off-normal operation only generating the first-order diffraction ($m = 1$) while reducing back-reflection (black arrow: the propagation constant in the waveguide region; purple arrow: the reciprocal lattice vector of the grating; red arrow: the wavevector of the upward-diffracted wave; green arrow: the wavevector of the downward-diffracted wave).
superstrate (diffracted toward the upward direction with a corresponding in-plane wavevector component of $k_{\text{super}} = 2\pi \cdot n_{\text{super}}/\lambda_0$) and the substrate (downward direction with an in-plane wavevector component of $k_{\text{sub}} = 2\pi \cdot n_{\text{sub}}/\lambda_0$), as illustrated in Figure 9.

When the effective optical wavelength inside the waveguide ($\lambda_0/n_{\text{eff}}$) matches the grating period ($\Lambda = \lambda_0/n_{\text{eff}}$), the waveguide propagation constant ($\beta$) becomes equivalent to the grating’s wavevector ($\beta = K$), as shown in Figure 9A. In this case, the second-order diffraction ($m = 2$) corresponds to the back-reflection ($k_{\text{back}} = \beta - 2K$) toward the silicon waveguide [117] and inevitably reduces the optical power in the first-order diffracted beam ($m = 1$) toward the vertical direction ($k_z = 0$). The vertically diffracted optical beam also has to go through multiple reflections between parallel optical interfaces, such as the silicon substrate, and therefore experiences Fabry-Pérot-type vertical oscillations. Therefore, such a grating coupler design with surface-normal diffraction ($\beta = K$, $k_z = 0$) is rarely used, and detuned off-normal grating designs are usually employed to improve the overall coupling efficiency [118], as shown in Figure 9B.

The diffraction angle to the superstrate ($\theta_{\text{super}}$) is a crucial parameter for grating coupler designs, and the diffraction angle for the first order beam ($m = 1$) can be expressed as $n_{\text{eff}} - n_{\text{super}} \cdot \sin \theta_{\text{super}} = \lambda_0/\Lambda$. According to this relationship, the diffraction angle strongly depends on the grating period ($\Lambda$), the optical wavelength ($\lambda_0$), and the effective index of the etched waveguide ($n_{\text{eff}}$). The effective refractive index for the waveguide also depends on the input polarization state. When the fill factor of the grating is $f = W/\Lambda$, where $W$ is the width of the un-etched grating teeth, the effective index of the grating ($n_{\text{eff}}$) is approximately given by $n_{\text{eff}} = f \cdot n_{\text{eff, unetched}} + (1-f) \cdot n_{\text{eff, etched}}$, where $n_{\text{eff, unetched}}$ and $n_{\text{eff, etched}}$ represent the effective index of the unetched and etched grating slot, respectively [84]. The fundamental TM mode typically shows a smaller effective index than that of the fundamental TE mode [96]. As can be seen from this analysis, the main drawbacks of grating-based coupling are its strong wavelength and polarization dependence, which limits the operating wavelength range and input polarization states.

### 3.2 Apodized grating structures

A variety of apodized grating couplers with spatially varying fill factors and etch depths has been reported to achieve high coupling efficiencies with large overlap integral values between the field profiles of diffracted light from the grating coupler structure and the free-space propagating beam from the optical fiber, as schematically shown in Figure 10A. In this schematic illustration, unlike our previous convention used in the previous section (e.g. Figure 2), we assume that the light propagation direction is from the integrated waveguides (waveguide 2 in Figure 2) to the optical fibers (waveguide 1 in Figure 2) for simplicity. Due to the reciprocity theorem, this does not change the results. The uniform grating structures cannot achieve very high coupling efficiencies because the output beam diffracted through the grating structure has an exponentially decaying asymmetric electric field profile ($E_0^*$, top in Figure 10A), rather than having a Gaussian-like symmetric distribution ($E_0^*$, bottom in Figure 10A) similar to the fiber mode ($\Sigma E_{\text{fib}}$) [119]. When the guided light in the waveguide is diffracted from an apodized grating coupler...
with spatially varying non-uniform grating elements, the output field distribution at the grating surface can resemble a Gaussian-like shape that can result in a higher mode overlap at the fiber facet \[120, 121\].

Figure 10B shows a shallow-etched apodized grating coupler with an optimized fill factor variation \[122\]. More specifically, the diffraction grating-based coupler was designed to provide an optical link between the single-mode optical fiber with a 10.4-μm MFD and the fundamental TE mode in the SOI-based PIC waveguide. The grating couplers were fabricated from an SOI wafer with a 340-nm-thick silicon device layer and a 2-μm-thick buried oxide layer. In order to achieve efficient mode matching and reduce back-reflection, the etch depth was optimized to 200 nm while the grating element fill factor was gradually changed from 0.08 to 0.4 along the waveguide propagation axis. As a result, the apodized grating structure achieved −1.2 dB (75.9%) efficiency at 1533 nm \[122\]. Recently, a high-efficiency grating coupler without a bottom reflector was reported by optimizing both the grating elements' fill factor and their periodicity \[111\]. The theoretical coupling efficiency for such an optimized grating coupler was estimated to be −0.8 dB (83.2%), and the experimental coupling efficiency of −0.9 dB (81.3%) was obtained. The samples were fabricated on an SOI wafer with a 260-nm device layer by electron beam lithography and a single-etch fabrication process.

More recently, a coupling efficiency of −0.7 dB (85.1%) near the 1310-nm wavelength was obtained by dual-etch apodized grating couplers \[123\]. High-efficiency grating couplers can be realized with multi-step etching techniques \[109, 110, 123\] and SWG structures \[100, 101, 124, 125\]. For example, a grating coupler with multiple etch depths achieved −1.9 dB (64.6%) coupling efficiency (Figure 10C) \[109\]. Subwavelength-scale diffractive elements, such as a photonic crystal structure, can also be used to implement a more efficient grating coupler \[125\].

### 3.3 Directionality-enhanced grating structures

Directionality \(P_{\text{up}}/P_{\text{wg}}\) shows the fraction of the waveguide input power \(P_{\text{wg}}\) that is diffracted to the upward direction \(P_{\text{up}}\). One of the main factors that reduce the grating coupler’s coupling efficiency is its low directionality because a significant fraction (35% – 45% \[112\]) of the input optical power to the waveguide is diffracted downward from the grating structure and becomes lost in the substrate, as shown in Figure 9. The basic rule of thumb for improving the directionality is to control the interference...
between the diffracted and reflected light components, which can be simply accomplished by tuning the thicknesses of the buried silicon oxide and cladding layers [114, 126] to maximize the outcoupled optical power toward the desired direction.

Figure 11A [127] schematically shows a method to improve the directionality with a substrate reflector, which is typically a Bragg reflector composed of alternating materials with high and low refractive indices, and reflects the downward diffracted light toward the upward direction to improve the directionality. Similar approaches have been introduced [113, 118, 127–129]. The reflectivity of the multilayer reflector is determined by the thicknesses of each layer, the refractive indices, and the number of such layers. For example, grating coupling structures with a Bragg bottom mirror made of Si/SiO₂ layers were demonstrated, and the measured coupling efficiency was −1.58 dB (69.5%) with a 1-dB bandwidth of 36 nm [127], as shown in Figure 11B.

The directionality can also be enhanced by employing a single mirror-like layer. A metal layer, such as an aluminum or gold layer, is also usually used to realize such a mirror-like layer [114, 130–133], and even an amorphous silicon layer can be adopted as a bottom mirror [134]. After the grating structures and the waveguides were defined on the SOI wafer, a SiO₂ top cladding layer was deposited. Then, the substrate of the wafer underneath the grating area was etched, and finally, a bottom reflector layer was deposited. The maximum measured coupling efficiency was −2 dB (63.1%) with a 1-dB bandwidth of 29 nm. The bottom reflector layer can also be assembled to the grating structures using flip-chip bonding [114, 134].

In addition, overlay grating elements can also improve the directionality by achieving constructive interference of P_up and reducing light leakage to the silicon substrate, as schematically described in Figure 11C. An epitaxially grown silicon layer can be used as an additional degree of freedom to the grating coupler design [112, 115, 135], and an example of a SEM image of a typical overlay grating is shown in Figure 11D [112]. The additional silicon layer on the un-etched grating teeth introduces an additional degree of freedom in the grating coupler design, and both the directionality and coupling length of the grating could be simultaneously optimized, overcoming the typical trade-off between the directionality and coupling length [112, 135]. After the grating structures were defined, an additional silicon layer was deposited and subsequently patterned and etched. When the unnecessary silicon overlay was removed by dry etching, the maximum coupling efficiency and 1-dB bandwidth were measured to be...

![Figure 11](image-url)

**Figure 11**: Diffraction grating-based optical coupling methods using directionality-enhanced grating structures. (A) Schematic diagram of a grating coupler with a backside mirror, enhancing the upward power (P_up) using interference effects. (B) SEM image of an example of the substrate reflector structure. Reprinted from Ref. [127]. Copyright (2009) The Optical Society. (C) Schematic diagram of a grating coupler with an overlay grating structure to reduce leakage. (D) SEM image of an example of a silicon overlay structure. Reprinted from Ref. [112]. Copyright (2010) The Optical Society.
−1.6 dB (69.2%) and 44 nm, respectively [112]. In ref. [115], two grating couplers were stacked by adding a second layer. Total film thickness was set to be 220 nm, and a simulated coupling efficiency of −0.137 dB was achieved.

Interleaved etching (dual-etch) processes were also adopted to improve directionality [136, 137]. A bi-level grating can be treated as a linear superposition of two gratings and generates constructive interference toward the superstrate and destructive interference toward the substrate [138]. Interleaved etching (70-nm and 220-nm depth) of a standard 220-nm-thick SOI platform resulted in a grating coupler with a coupling efficiency of −1.3 dB and a 3-dB bandwidth of 52 nm [137].

Enhancing the directionality is crucial to ensure that the grating coupler achieves high coupling efficiencies. The design strategies and fabrication schemes for the grating-based optical coupler should be carefully chosen considering the overall fabrication process flows and packaging situations.

4 Adiabatic coupling

Adiabatic coupling (or evanescent coupling) can achieve highly efficient wavelength-independent coupling between two adiabatically tapered waveguides. In this scheme, in order to match the effective modal index, both waveguides are inversely tapered to reduce the effective modal refractive index down to the refractive index of the surrounding cladding material(s) (e.g. silicon dioxide or air). Although the tapered waveguide geometries are also employed in the end-fire coupling schemes (Section 2.3 [39–42, 56–59, 62–67] and Section 2.4 [43, 79]), the main difference in adiabatic coupling is that the optical power transfer between the input and output waveguides is achieved through evanescent coupling. In the end-fire coupling scheme, the optical power from the input waveguide arrives at the front facet of the output waveguide at which the coupling efficiency can be determined by the field overlap. However, for the adiabatic coupling scheme, the optical power transfer from the input waveguide to the output waveguide continuously occurs through evanescent coupling over the waveguide interaction region where two waveguides’ optical modes spatially overlap with each other. To facilitate evanescent power transfer, the waveguide dimensions need to be close to or within the subwavelength scale so that the optical mode profiles reside mostly outside the waveguide core region.

In the early 2000s, many research groups adopted tapered optical fibers for efficient optical power transmission to silica-based [139–141] and semiconductor-based microcavities [142]. For this type of waveguide-to-resonator coupling applications, critical coupling conditions between the access waveguide and the resonator are typically preferred for an optimal balance between the coupling loss and the resonator loss, and therefore, it does not require complete optical power transfer. Although the similarly tapered optical fibers are used for adiabatic coupling to and from the integrated PIC waveguides, the coupling regime is quite different from the critical coupling case.

Early works on adiabatic waveguide coupling were based on biconical tapered fibers [143, 144] and conical tapered fibers [145]. Emerging applications, such as single-photon-level integrated quantum optics, need very high optical coupling efficiency, close to 100%, which represent the extreme cases of reliable and predictable photon transfer between waveguides. In addition, the adiabatic waveguide coupling method can also be applied for testing and characterization of on-chip photonic components [146]. Table 3 lists the performances of various adiabatic coupling examples.

4.1 Principle of operation

To further improve the optical coupling efficiency of conventional end-fire coupling methods, the adiabatic waveguide coupling scheme uses a longer coupling distance with the slower transformation of the guided modes with the tapered

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Year</th>
<th>Fiber</th>
<th>Coupling (TE) efficiency (dB)</th>
<th>Operation wavelength (nm)</th>
<th>Fiber fabrication</th>
<th>Comments</th>
</tr>
</thead>
<tbody>
<tr>
<td>[144]</td>
<td>2004</td>
<td>Biconical</td>
<td>−0.223</td>
<td>1565–1625</td>
<td>Heating and pulling</td>
<td>Silicon WG/vertical coupling</td>
</tr>
<tr>
<td>[147]</td>
<td>2013</td>
<td>Biconical</td>
<td>−0.223</td>
<td>1550</td>
<td>Heating and pulling</td>
<td>Silicon WG/vertical coupling</td>
</tr>
<tr>
<td>[145]</td>
<td>2015</td>
<td>Conical</td>
<td>−0.132 (−0.044*)</td>
<td>780</td>
<td>Heating and pulling</td>
<td>SIN WG/lateral coupling</td>
</tr>
<tr>
<td>[148]</td>
<td>2016</td>
<td>Biconical</td>
<td>−7.85 − −4.32 (−1.549*)</td>
<td>780</td>
<td>Heating and pulling</td>
<td>Diamond WG/vertical coupling</td>
</tr>
<tr>
<td>[149]</td>
<td>2017</td>
<td>Conical</td>
<td>−0.362</td>
<td>780</td>
<td>Chemical etching</td>
<td>Diamond WG/vertical coupling</td>
</tr>
<tr>
<td>[150]</td>
<td>2018</td>
<td>Conical</td>
<td>−0.017*</td>
<td>1550</td>
<td>Chemical etching</td>
<td>Silicon WG/lateral coupling</td>
</tr>
</tbody>
</table>

The coupling efficiencies with “*” indicate the simulated results.
input and output waveguides, as schematically shown in Figure 12A. The key idea of adiabatic light coupling between tapered fibers and inversely tapered waveguides is to slowly and adiabatically transform the waveguides modal cross-section along the propagation direction such that the propagating electromagnetic field profile remains in a single eigenmode through the composite waveguide region where both the tapered input and output waveguides overlap with each other (e.g. a combination of tapered optical fibers and silicon waveguides). To suppress higher order mode excitation and the corresponding optical losses, both waveguides should be gradually tapered and fulfill the adiabatic condition [151, 152]. For example, specially designed fibers, such as tapered and pulled fibers with wavelength- or subwavelength-scale core/cladding dimensions in contrast to the cleaved or lensed fibers in the previous sections, are used to efficiently generate evanescent optical fields. With adiabatically varying waveguides, the optical coupling length between two waveguides is given by $\lambda_0/(n_{\text{eff,1}} - n_{\text{eff,2}})$, where $n_{\text{eff,1}}$ and $n_{\text{eff,2}}$ are the effective refractive indices of the two eigenmodes [153]. As a result, nearly 100% power transfer can be obtained between two waveguides when the waveguide interaction length is longer than the coupling length, $\lambda_0/(n_{\text{eff,1}} - n_{\text{eff,2}})$.

4.2 Broadband optical coupling in the visible and infrared wavelength range

To obtain evanescent coupling between the optical fibers and the integrated waveguides, biconical tapered optical fibers were used [143, 144, 147, 148]. The waveguide interaction distance was up to ~25-μm long [147]. Single-sided conical tapered fibers can also be used for adiabatic coupling [145, 149, 150]. For single-sided conical tapered fiber fabrication, a chemical etching method was used [149, 150]. In contrast to the biconical fibers, single-sided geometries can offer better mechanical stability and compactness suitable for coupling with the PIC chips [145]. Highly efficient optical coupling, up to $-0.13$ dB (97%), was achieved with very compact coupling interfaces [145].

Figure 12B shows a schematic diagram of fiber-to-silicon nitride waveguide coupling [145]. By following the adiabatic tapering condition discussed in Section 4.1, the optical modes can be evanescently coupled between two waveguides, as shown in Figure 12C. The reported results have focused on the visible wavelength range operation with silicon nitride [145] and diamond [149] waveguides. High-efficiency optical coupling schemes with silicon waveguides in the near-infrared wavelengths were also proposed with an adiabatically tapered silica fiber whose full tip angle was $\sim 1.2^\circ$ [150].

The advantages of adiabatic coupling include a large 1-dB alignment tolerance dimensions up to ~50 μm along the waveguide optical axis [149], a wide 1-dB bandwidth larger than a wavelength range of 200 nm [147, 149, 150], and very high coupling efficiencies. However, in this scheme, the integrated waveguides need to be suspended and surrounded by lower index materials, such as air, to prevent the optical power leakage to the other cladding layers, and therefore, additional processing steps are required as in Section 2.3.

![Figure 12](image-url)

**Figure 12**: (A) Schematic diagram of the fiber-waveguide coupling scheme. (B) Adiabatic coupling between high-index SiN waveguide (right) and low-index tapered optical fiber (left). (C) The corresponding cross-sectional of $|E|^2$ obtained from the FDTD simulations at various positions along the adiabatic couplers.

Adapted from Ref. [145]. Copyright (2015) The Optical Society.
5 Conclusion

In this paper, we reviewed the development progress of three major light coupling methods between the optical fibers and the integrated waveguides for PICs: end-fire coupling, diffraction grating-based coupling, and adiabatic coupling. High-index material-based optical waveguide structures and their integration with other optical devices in the PIC platforms have resulted in large-scale integration and miniaturization of photonic devices and systems. For example, well-developed microfabrication technologies and infrastructures enable silicon-based integrated photonic technologies to be a promising platform for large-scale heterogeneous optoelectronic integration and may provide economies of scaling and high manufacturing yields for integrated optoelectronics. However, high-efficiency transmission of optical signals into and out of such PIC platforms with a reliable yet cost-effective packaging solution is still an important and critical issue in solving the interface bottleneck.

The end-fire coupling methods, which were first introduced in the 1970s with relatively low port counts, require that the PIC chips be diced and cleaved. In order to provide wafer-level characterization capabilities and scalable interfaces between the optical fibers and PICs, surface-normal coupling methods using diffractive grating structures were introduced and resulted in greater layout design flexibilities and scalabilities in optical port counts. However, the grating-based methods typically show wavelength and polarization dependencies. More recently, adiabatic coupling methods have been introduced that can reduce the wavelength and polarization dependence while allowing more compact and wafer-scale interfaces to the optical fibers.

In addition to the three major coupling methods discussed in this paper, we expect that fiber-to-PIC coupling techniques will further evolve to meet the future needs to support various types of fibers and integrated optoelectronics as well as advanced optical signaling formats. For example, multi-core or multimode fibers can take advantage of space division multiplexing technologies to provide compact multi-channel optical interfaces to the integrated photonic circuits. Emerging examples to provide a simple connectivity between multimode fibers and integrated photonic components, such as surface-normal emitters and detectors, include end-fire coupling [154] and grating-based coupling techniques [155]. One can envision that advances in photonics, especially nanophotonics, will enable highly efficient, reliable, and seamless optical interfaces between heterogeneous optical platforms for high-performance optoelectronic systems with higher coupling efficiencies and better alignment tolerances.

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